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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of :
Hiroto YUKAWA et al. : Docket No. 2004_0499
Serial No. 10/810,902 :
Filed March 29, 2004 :

POSITIVE-WORKING CHEMICAL-
AMPLIFICATION PHOTORESIST
COMPOSITION

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In the interest of compact prosecution, please amend the present application as follows: